

CHLORINE DIOXIDE GENERATED IN SITU

Operator generated in situ chemical, United Kingdom, United Kingdom

Registration No: 4679 **Version No:** 10 **Expiry Date:** 03/02/2029

NL HMCS Prescreening Category: E

Application Process System		Dose Rate		Worst Aquatic Toxicity Test		Number of Aquatic Toxicity Tests		OCNS Group		100% PLONOR
CHARM is not applicable to this process system		1000000 ppm		N/A		N/A		E		No

Application	Surfactant Type	Sediment Reworker	Drilling Mud Density kg/m3	Biodegradation Value/%	Time/Days	Protocol	Minimum LogPow	Koc	Koc Protocol	Organic C Content
CHARM N/A	N/A	N/A	N/A	N/A	N/A	N/A	N/A	N/A	N/A	N/A

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